

IN THE CLAIMS

Please amend the claims as follows:

Claim 1 (Currently Amended): A silver alloy comprising ~~a composition containing at least four elements including~~ Ag (silver) as its major component, 0.10 to 2.89 wt% of Pd (palladium), 0.10 to 2.89 wt% of Cu (copper) and 0.01 to 1.50 wt% of Ge (germanium), and wherein the total amount of Pd, Cu and Ge is 0.21 to 3.00 wt%.

Claim 2 (Currently Amended): The silver alloy according to Claim 1, wherein the silver alloy consists of Ag, Pd, Cu and Ge ~~having a composition excluding any component other than the four elements~~ and wherein the content of the Ag in the alloy is 97.00 to 99.79 wt%.

Claim 3 (Currently Amended): The silver alloy according to Claim 1 ~~or 2~~, wherein the ratio of the content of Cu to the content of Ge, ~~namely~~, Cu content/Ge content, is 1/20 ~~(1/20) to (20/1)~~ 20/1.

Claim 4 (Currently Amended): The silver alloy according to Claim 1 ~~or 2~~, wherein the silver alloy, after being heat-treated at 250°C, for one hour, in air, having ~~has~~ a reflectance of 90% or more for light having a wavelength of 550 nm ~~after heat-treated at 250°C for one hour in air.~~

Claim 5 (Currently Amended): The silver alloy according to Claim 3, wherein the silver alloy, after being heat-treated at 250°C, for one hour, in air, having ~~has~~ a reflectance of 90% or more for light having a wavelength of 550 nm ~~after heat-treated at 250°C for one hour in the air.~~

Claim 6 (Currently Amended): The silver alloy according to Claim 1 ~~or 2~~, wherein the silver alloy, after exposure to a 100 ppm hydrogen sulfide atmosphere, at ambient temperature, for 48 hours, having ~~has~~ a reflectance of 75% or more for light having a wavelength of 550 nm ~~after exposed to a 100 ppm hydrogen sulfide atmosphere at ambient temperature for 48 hours.~~

Claim 7 (Currently Amended): The silver alloy according to Claim 3, wherein the silver alloy, after exposure to a 100 ppm hydrogen sulfide atmosphere, at ambient temperature, for 48 hours, has ~~having~~ a reflectance of 75% or more for light having a wavelength of 550 nm ~~after exposed to a 100 ppm hydrogen sulfide atmosphere at ambient temperature for 48 hours.~~

Claim 8 (Currently Amended): The silver alloy according to Claim 1 ~~or 2~~, wherein the silver alloy, after exposure to a high temperature and high humidity atmosphere of 85°C and 90 RH%, for 200 hours, has ~~having~~ a reflectance of 88% or more for light having a wavelength of 550 nm ~~after exposed to a high temperature and high humidity atmosphere of 85°C and 90 RH% for 200 hours.~~

Claim 9 (Currently Amended): The silver alloy according to Claim 3, wherein the silver alloy, after exposure to a high temperature and high humidity atmosphere of 85°C and 90 RH%, for 200 hours, has ~~having~~ a reflectance of 88% or more for light having a wavelength of 550 nm ~~after exposed to a high temperature and high humidity atmosphere of 85°C and 90 RH% for 200 hours.~~

Claim 10 (Currently Amended): The silver alloy of Claim 1, wherein the silver alloy is in the form of a sputtering target ~~sputtering target material formed of the silver alloy as claimed in Claim 1, 2, 3, 4, 5, 6, 7, 8 or 9.~~

Claim 11 (Currently Amended): The silver alloy of Claim 1, wherein the silver alloy is in the form of a thin film ~~thin film formed of the silver alloy as claimed in Claim 1, 2, 3, 4, 5, 6, 7, 8 or 9.~~

Claim 12 (Currently Amended): The ~~silver alloy~~ thin film according to Claim 11, wherein the silver alloy thin film, after heat-treatment at 250°C, for one hour, in air, has having a reflectance of 90% or more for light having a wavelength of 550 nm ~~after heat-treated at 250°C for one hour in the air.~~

Claim 13 (Currently Amended): The ~~silver alloy~~ thin film according to Claim 11, wherein the silver alloy thin film, after exposure to a 100 ppm hydrogen sulfide atmosphere, at ambient temperature, for 48 hours, has having a reflectance of 75% or more for light having a wavelength of 550 nm ~~after exposed to a 100 ppm hydrogen sulfide atmosphere at ambient temperature for 48 hours.~~

Claim 14 (Currently Amended): The ~~silver alloy~~ thin film according to Claim 11, wherein the silver alloy thin film, after exposure to a high temperature and high humidity atmosphere of 85°C and 90 RH% for 200 hours, has having a reflectance of 88% or more for light having a wavelength of 550 nm ~~after exposed to a high temperature and high humidity atmosphere of 85°C and 90 RH% for 200 hours.~~

Claim 15 (Currently Amended): The ~~silver-alloy~~ thin film according to Claim 11, ~~12,~~  
~~13 or 14, wherein the said silver-alloy thin film being~~ is a reflecting film.

Claim 16 (Currently Amended): The ~~silver-alloy~~ thin film according to Claim 11, ~~12,~~  
~~13 or 14, said silver-alloy wherein the thin film being~~ is a ~~thin type~~ semi-transmissive film.

Claim 17 (Currently Amended): The ~~silver-alloy~~ thin film according to Claim 11, ~~12,~~  
~~13 or 14, said silver-alloy wherein the thin film being~~ is a patterned electrode or wiring.

Claim 18 (Currently Amended): The reflecting film of Claim 15, wherein the  
reflecting film is in the form of a self-emitting type display ~~A self-emitting type display~~  
~~comprising the reflecting film as claimed in Claim 15 or a perforated semi-transmissive film~~  
~~obtained by forming light transmissive holes that transmit a part of incident light in the~~  
~~reflecting film as claimed in Claim 15.~~

Claim 19 (Currently Amended): The reflecting film of Claim 15, wherein the  
reflecting film is in the form of a flat panel display ~~A flat panel display comprising the~~  
~~reflecting film as claimed in Claim 15 or a perforated semi-transmissive film obtained by~~  
~~forming light transmissive holes that transmit a part of incident light in the reflecting film as~~  
~~claimed in Claim 15.~~

Claim 20 (Currently Amended): The reflecting film of Claim 15, wherein the  
reflecting film is in the form of an electrode ~~A reflecting electrode comprising the reflecting~~  
~~film as claimed in Claim 15 or a perforated semi-transmissive film obtained by forming light~~

~~transmissive holes that transmit a part of incident light in the reflecting film as claimed in Claim 15.~~

Claim 21 (Currently Amended): The reflecting film of Claim 11, wherein the reflecting film is in the form of an electronic part ~~Electronic parts comprising using the silver alloy thin film as claimed in Claim 11, 12, 13, 14, 15, 16 or 17.~~

Claim 22 (Currently Amended): The reflecting film of Claim 15, wherein the reflecting film is in the form of an optical disk ~~An optical disk medium comprising at least one of the reflecting film as claimed in Claim 15 and the thin type semi-transmissive film as claimed in Claim 16.~~

Claim 23 (Currently Amended): The reflecting film of Claim 15, wherein the reflecting film is in the form of a light part ~~Light parts comprising the reflecting film as claimed in Claim 15.~~

Claim 24 (Currently Amended): ~~A silver alloy thin~~ The reflecting film according to Claim 15, wherein ~~said silver alloy thin~~ the reflecting film is an electromagnetic shielding film.

Claim 25 (Currently Amended): The silver alloy of Claim 1, wherein the silver alloy is in the form of a silver alloy paste ~~A silver alloy paste, material formed of the silver alloy as claimed in Claim 1, 2, 3, 4, 5, 6, 7, 8 or 9.~~